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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

Confirmation No. 8095

Miwa KOZAWA

Art Unit: 1712

Application No.: 10/005,347

Filed: 12/07/2001

Attorney Dkt. No.: 100021-00065

Examiner: Kuo Liang Peng

For: SILICON-CONTAINING POLYMER, PROCESS FOR ITS PRODUCTION, RESIST COMPOSITION EMPLOYING IT, PATTERN-FORMING METHOD AND ELECTRONIC

DEVICE FABRICATION METHOD

AMENDMENT UNDER 37 CFR § 1.111

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

September 4, 2003

Sir:

This paper is filed in response to the Office Action dated June 4, 2003, in connection with the above-identified patent application. Applicants respectfully request entry of the following amendments without prejudice.